

IEEE Computer Society Workshop on Biometrics
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With a very security conscious society, biometrics based authentication and identification have become center of focus for many important applications as it is believed that biometrics can provide accurate and reliable identification. Biometrics research and technology continue to mature rapidly, driven by pressing industrial and government needs and supported by industrial and government funding. As the number and types of biometrics architectures and sensors increase, the need to disseminate research results increases as well. This workshop is positioned at the frontier of biometrics research to showcase advanced work that is underway in academia and industry.

We would like to thank the Program Committee for their timely and valuable reviews of the papers. We received over 32 papers and accepted 10 papers for full presentations and 11 for short presentations. Each paper was reviewed by at least three program committee members. The papers have been grouped under the sections: Face, 3D models, Multimodal biometrics, Systems and Security, and Quality.

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Bir Bhanu , Nalini K. Ratha , Venu Govindaraju

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